

Title (en)

IRON BASE POWDER MIXTURE FOR POWDER METALLURGY EXCELLENT IN FLUIDITY AND MOLDABILITY, METHOD OF PRODUCTION THEREOF, AND METHOD OF PRODUCTION OF MOLDED ARTICLE BY USING THE IRON BASE POWDER MIXTURE

Title (de)

PULVERMISCHUNG AUF EISENBASIS FÜR DIE PULVERMETALLURGIE MIT HERVORRAGENDEN FLIESS- UND FORMEIGENSCHAFTEN, VERFAHREN ZU DEREN HERSTELLUNG, UND VERFAHREN ZUR HERSTELLUNG EINES DURCH VERWENDUNG DER PULVERMISCHUNG AUF EISENBASIS GEFORMTEN GEGENSTANDS

Title (fr)

MELANGE PULVERISE A BASE DE FER DESTINE A LA METALLURGIE DES POUDRES, DOTE D'EXCELLENTE CARACTERISTIQUES DE FLUIDITE ET D'APTITUDE AU MOULAGE, PROCEDE DE PRODUCTION CORRESPONDANT ET PROCEDE DE PRODUCTION D'ARTICLE MOULE UTILISANT LEDIT MELANGE PULVERISE A BASE DE FER

Publication

EP 0913220 A4 20060412 (EN)

Application

EP 98909734 A 19980318

Priority

- JP 9801147 W 19980318
- JP 6676797 A 19970319

Abstract (en)

[origin: EP0913220A1] The present invention intends to provide an iron-based powder composition for powder metallurgy having excellent flowability at room temperature and a warm compaction temperature, having improved compactibility enabling lowering ejection force in compaction, to provide a process for producing the iron-based powder composition, and to provide a process for producing a compact of a high density from the iron-based powder composition. The iron-based powder composition comprises an iron-based powder, a lubricant, and an alloying powder, and at least one of the iron-based powder, the lubricant, and the alloying powder is coated with at least one surface treatment agent selected from the group of surface treatment agents of organoalkoxysilanes, organosilazanes, titanate coupling agents, fluorine-containing silicon silane coupling agents. The iron-based powder composition is compacted at a temperature not lower than the lowest melting point of the employed lubricants, but not higher than the highest melting point of the employed lubricants.

IPC 1-7

B22F 1/02; **C22C 33/02**

IPC 8 full level

B22F 1/10 (2022.01); **B22F 1/102** (2022.01); **B22F 1/148** (2022.01); **C22C 33/02** (2006.01)

CPC (source: EP US)

B22F 1/10 (2022.01 - EP US); **B22F 1/102** (2022.01 - EP US); **B22F 1/108** (2022.01 - EP US); **B22F 1/148** (2022.01 - EP US); **C22C 33/0207** (2013.01 - EP US); **B22F 2998/00** (2013.01 - EP US)

Citation (search report)

- [X] US 5135566 A 19920804 - SAKURANDA ICHIO [JP], et al
- See references of WO 9841347A1

Cited by

EP1688199A4; CN107107189A; EP2179807A4; CN101920335A; EP1145788A4; EP2359963A4; EP1199124A4; EP3962677A4; US7582255B2; US9108246B2; US6573225B1; WO0119554A1; WO0149439A1; EP0946322B1; US6861028B2; WO2020220143A1

Designated contracting state (EPC)

SE

DOCDB simple family (publication)

EP 0913220 A1 19990506; **EP 0913220 A4 20060412**; **EP 0913220 B1 20081210**; TW 416878 B 20010101; US 2001028859 A1 20011011; US 6235076 B1 20010522; US 6503445 B2 20030107; WO 9841347 A1 19980924

DOCDB simple family (application)

EP 98909734 A 19980318; JP 9801147 W 19980318; TW 87104086 A 19980319; US 17191198 A 19981028; US 76711101 A 20010122